

NNT 2020

October 7-9, 2020

Toyama International Conference
Center, Toyama, Japan

Web. <http://nanoimprint.jp/nnt2020/>

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**Paper Deadline
May 29, 2020**

SCOPE

- 1) Processes (Thermal, UV, R to R, others)
- 2) Large area and high throughput approaches
- 3) Materials (Resist, Anti-sticking)
- 4) Template
- 5) Tools
- 6) Modelling, simulation and inspection
- 7) Related and emerging methods (soft lithography, self-assembly, others)
- 8) Applications (Electronics, Integrated circuit, Optics, Bio, Energy, other micro-nano devices)

SECRETARIAT

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